Graduate School of Information, Production and Systems, Waseda University

Time Table 2025-2026

1period 8:50~10:30, 2 period 10:40~12:20, 3 period 13:10~14:50, 4 period 15:05~16:45, 5 period 17:00~18:40, 6 period 18:55~20:35

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FS: Fundamental Subjects, AS: Advanced Subjects, SS: Specialized Subjects, E: Exercises, LW: Laboratory Works

Ask the lecturer for the lecture room if it is blank.

*There might be some updates for classes information. Please check on our bulletin board by the administration office or IPS square(https://www.waseda.jp/fsci/gips/other-en/2024/03/12/26339/) as needed.

*Please check with the syllabus (https://www.wsl.waseda.jp/syllabus/JAA101.php?pl.ng=en) or the instructor in charge of the course for the method of conducting classes.